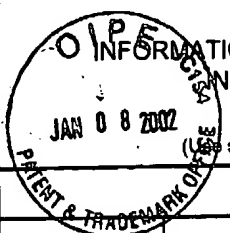


FORM PTO-1449			Docket Number (Optional) 1-22531/US/AO/UBT 2/PCT		Application Number 09/914,700		
			Applicant HANS-WERNER SCHMIDT ET AL				
			Filing Date AUGUST 31, 2001		Group Art Unit		
U. S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
KS	3,367,926	2/68	Voeks	260	93.5		
KS	5,278,216	1/94	Asanuma et al	524	394		
KS	4,294,747	10/81	Su	260	37		
KS	5,137,973	8/92	Khanna et al	525	177		
KS	4,749,736	6/88	Khanna et al	524	230		
KS	4,694,064	9/87	Tomalia et al	528	332		
KS	4,338,228	7/82	Inoue et al	524	120		
KS	3,852,237	12/74	Osborn et al	260	42.21		
KS	5,574,174	11/96	Syed	549	364		
KS	5,198,484	3/93	Mannion	524	108		
KS	5,216,051	6/93	Smith et al	524	108		
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
KS	0780428	6/97	Europe				
KS	60252655	12/85	Japan				
KS	0278409	8/88	Europe				
KS	2310860	9/97	Great Britain				
KS	95/13317	5/95	PCT/World				
OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)							
KS	Derwent Abstr, 86-032017/05 for JP 60252655 (1985)						
KS	Chem. Abstr. 125:309830 for Adv. Mater., (1996), Vol. 8, No. 9, pp. 740-741						
KS	Bielstein Registry No. 1989871, Ref. 1646400 for Journal Isoshima, NPKZAZ, Nippon Kagaku Zasshi, Vol. 77, (1956), 422, 431,						
EXAMINER <i>Knut Sanders</i>			DATE CONSIDERED 7/07				
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.							







<b>FORM PTO-1449</b>  <b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  (Use several sheets if necessary)				Docket Number (Optional) <b>1-22531/US/AO/UBT 2/PCT</b>		Application Number <b>09/914,700</b>	
<div style="border: 1px solid black; border-radius: 50%; padding: 10px; display: inline-block; text-align: center;">             OFFICE OF              INFORMATION DISCLOSURE              JAN 08 2002              TRADEMARK OFFICE           </div>				Applicant <b>HANS-WERNER SCHMIDT ET AL</b>			
				Filing Date <b>AUGUST 31, 2001</b>		Group Art Unit	

U. S. PATENT DOCUMENTS						
INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

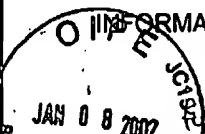
  

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)	
KS	A. Wlochowicz et al., Die Angewandte Makromolekulare Chemie, Vol. 171, (1989), pp. 79-89 (No. 2741)
KS	H. Beck, Journal of Applied Polymer Science, Vol. 11, pp. 673-685 (1967)
KS	F. Binsbergen, Polymer, Vol. 11, pp. 253-267, (1970)

EXAMINER <i>Kueltter Sanders</i>	DATE CONSIDERED <i>7/01</i>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

FORM PTO-1449  	Docket Number (Optional) 1-22531/US/AO/UBT 2/PCT	Application Number 09/914,700
	Applicant HANS-WERNER SCHMIDT ET AL	
	Filing Date AUGUST 31, 2001	Group Art Unit
	INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	

## U. S. PATENT DOCUMENTS


INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
					YES	NO

## OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)

KS	R. Schlotmann et al., Kunststoffe, Vol. 86, No. 7, (1996) pp. 1002-1006
KS	R. Morrison et al., Organic Chemistry, 2 <sup>nd</sup> Ed., (1966), p. 893

EXAMINER 	DATE CONSIDERED 7/08
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.